

FORM PTO-1449
(REV. 7-80)US. DEPARTMENT OF COMMERCE
PATENT AND TRADEMARK OFFICEATTY. DOCKET NO.
RD-28,965-1

SERIAL NO.

INFORMATION DISCLOSURE STATEMENT BY APPLICANT
LIST OF ITEMSApplicant
Marc SchaepekensFiling Date
5/23/02Group Art Unit
1775

U.S. PATENT DOCUMENTS & PATENT APPLICATION PUBLICATION

*EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
	A1					
	A2					
	A3					
	A4					
	A5					
	A6					
	A7					
	A8					
	A9					

FOREIGN PATENT DOCUMENTS

		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION YES NO
LX	B1	WO 01/81649	1NOV01	PCT			X
↓	B2	EP0460966	11DEC91	European			X
	B3	FR 2712310	19MAY95				

OTHER INFORMATION (Including Author, Title, Date, Pertinent Pages, etc.)

LX	C1	Osamu Fukumasa, "Synthesis of New Ceramics From Powder Mixtures Using Thermal Plasma Processing", Elsevier, Thin Solid Films, 390, pages 37-43, 2001.
	C2	
	C3	
	C4	
	C5	
	C6	
	C7	
	C8	

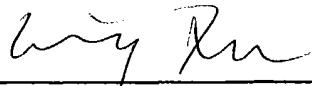
EXAMINER

Wing Xu

DATE CONSIDERED

6/25/04

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant

FORM PTO-1449 (REV. 7-80)		U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE		ATTY. DOCKET NO. RD-28,965		SERIAL NO.	
INFORMATION DISCLOSURE STATEMENT BY APPLICANT <u>LIST OF ITEMS</u>				Applicant Marc (NMN) Schaepekens			
				Filing Date		Group 1775	
U.S. PATENT DOCUMENTS							
*EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE	
LX	A1	4,871,580	10/3/89	Schram et al.			
LX	A2	6,110,544	8/29/00	Yang et al.			
	A3						
	A4						
	A5						
FOREIGN PATENT DOCUMENTS							
	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION YES NO	
	B1						
	B2						
OTHER INFORMATION (Including Author, Title, Date, Pertinent Pages, etc.)							
LX	C1	Application Serial No. 09/681,820, filed June 11, 2001, "Apparatus and Method for Large Area Chemical Vapor Deposition Using Multiple Expanding Thermal Plasma Generators".					
	C2	Application Serial No. 09/836,657, filed April 17, 2001, "A Transparent Flexible Barrier for Liquid Crystal Display Devices and Method of Making the Same."					
	C3	Application Serial No. 09,683,148, filed November 27, 2001, "Apparatus and Method for Depositing Large Area Coatings on Non-Planar Surfaces".					
	C4	Application Serial No. 09,683,149, filed November 27, 2001, "Apparatus and Method for Depositing Large Area Coatings on Planar Surfaces".					
	C5	Philips Research Password, "Flexible Displays Cast Off Rigid Constraints", Dr. Peter Slikkerveer, Issue 10, Issue 10, pp 5-7, January 2002.					
	C6	Appl. Phys. Letter, "Etch Mechanism in the Refractive Index Silicon Nitride Plasma-Enhanced Chemical Vapor Deposition Process, Yeo Kuo, Volume 63, No. 2, pp 144-146, July 12, 1993					
	C7	American Vacuum Society, "Transparent Barrier Coatings on Polyethylene Terephthalate By Single- and Dual-Frequency Plasma-Enhanced Chemical Vapor Deposition", A. S. da Silva Sobrinho et al, A, Volume 16, No. 6, pp 3190-3198, Nov/Dec 1998.					
	C8						
EXAMINER 				DATE CONSIDERED 6/29/04			
EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant							